

FIS920000310051
Eric V. Kline
1/5

Figure 1

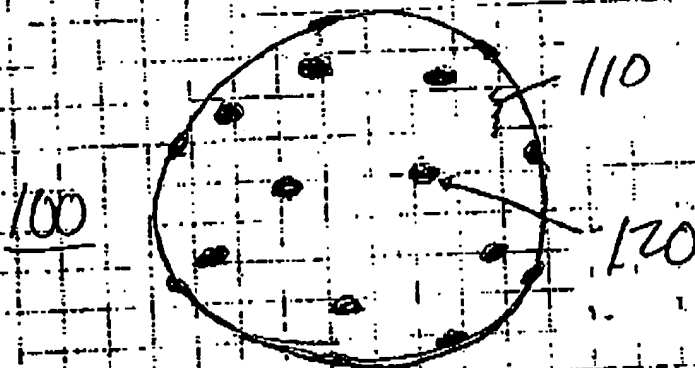
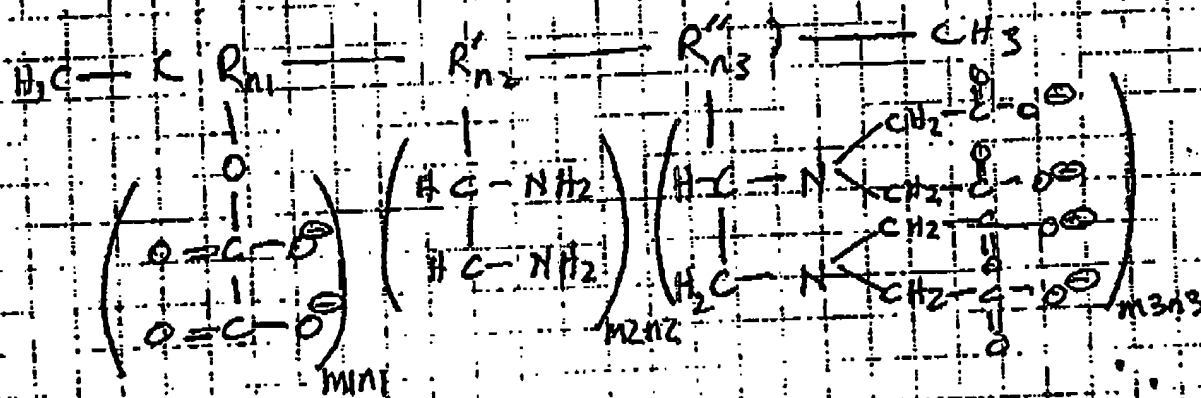


Figure 2



NOV 21 '00 09:37 FR IBM MICROELECTRONICS 8458926214 TO 917037612375 P.03/06

FIS920000310US1
Eric V. Kline
2/5

Figure 3.

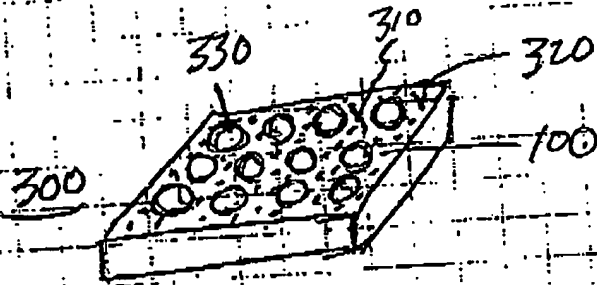


Figure 4.

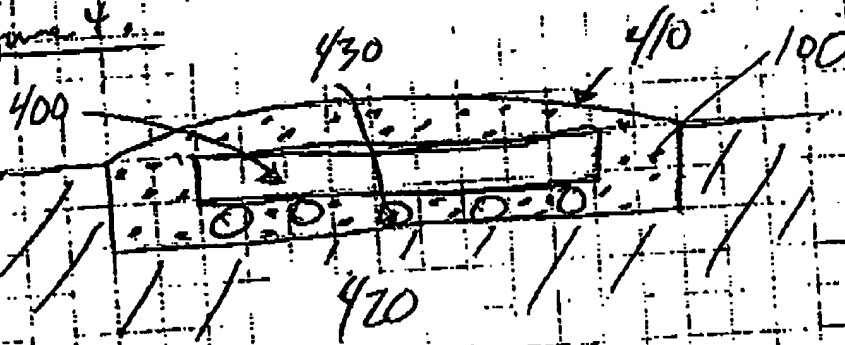
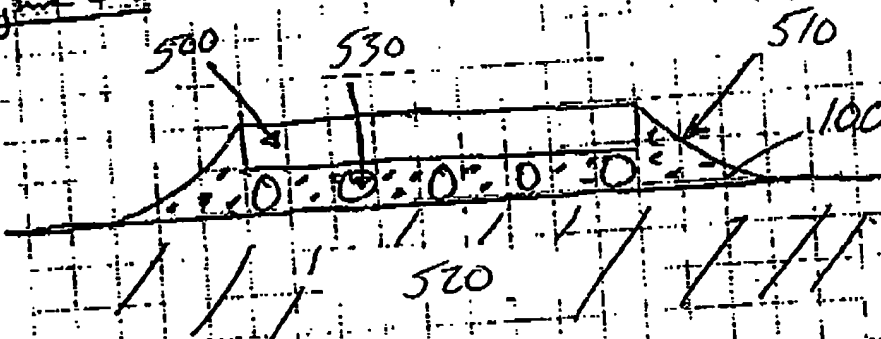


Figure 5.



NOV 21 '00 09:37 FR IBM MICROELECTRONICS 8458926214 TO 917037612375

P.04/06

PIS920000310US1

Eric V. Kline
3/5

Figure 6

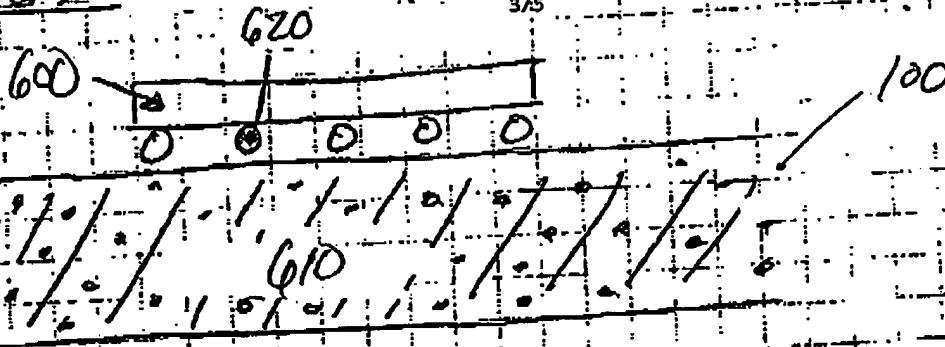
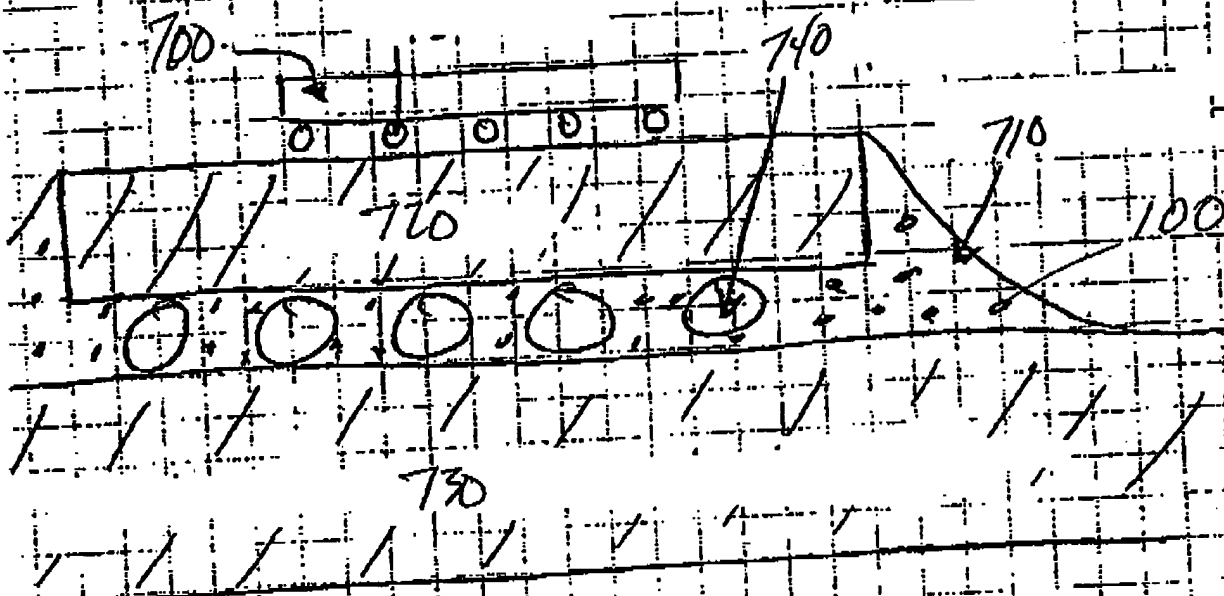


Figure 7



NOV 21 '00 09:38 FR IBM MICROELECTRONICS 8458926214 TO 917037612375

P.05/16

PIS920000310US1
Eric V. Kline
4/5

Figure 8.

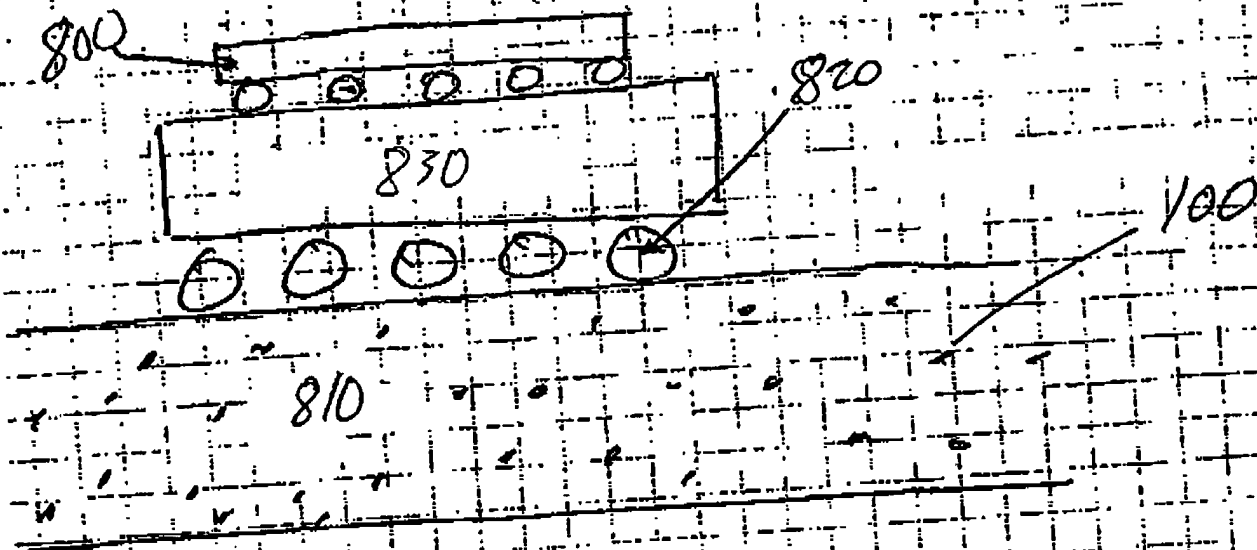
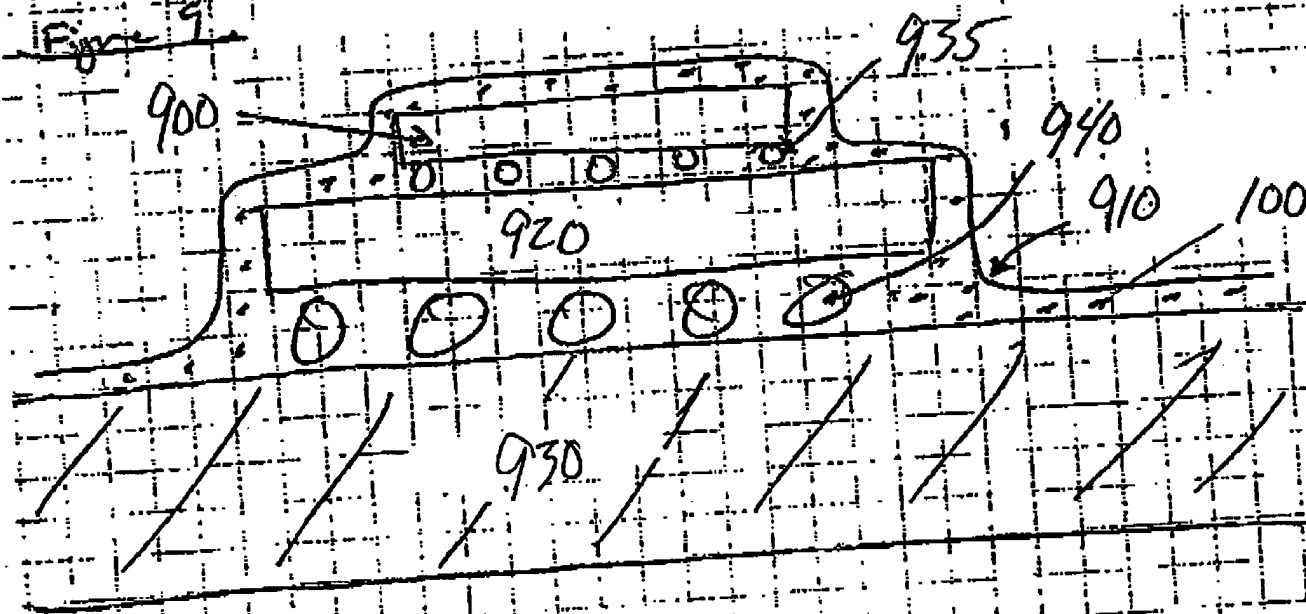


Figure 9.



FIS9200003100S1
Eric V. Kline
5/5

Bond chelating agent to
an immobile particle to
form a composite

(955)

Deposit composite in
close proximity to metal source

(960)

Using chelating agent to
capture metal ions which
have leached out of
metal source

(965)

950

Figure 10.